Approved for use through 07/31/2012. OMB 0651-0031
U.S. Patent and Trademark Office: U.S. DEPARTMENT OF COMMERCE

Under	the Paperwork Red	luction Ac	t of 1995, no persons are		of information unless it contains a valid OMB control number.		
Substitute for form 1449/PTO				Complete if Known			
				Application Number	pplication Number 10/725,965		
			CLOSURE	Filing Date	December 2, 2003		
STATEMENT BY APPLICANT				First Named Inventor	Erik Buntinx		
	(Use as many she	ets as n	ecessary)	Art Unit	1617		
(Social many shoots as hostically)				Examiner Name	Umamaheswari Ramachandran		
Sheet 1		of	1	Attomey Docket Number	29248-18		

		NON PATENT LITERATURE DOCUMENTS	
Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T ²
/U.R./	1	WADE, Alan G, et al., "Addition of a Selective 5-HT2A/D4 Antagonist Accelerates the Antidepressant Effects of Citalopram." Poster presented 12/09/09, ACNP, Hollywood, FL.	
			_

Examiner Signature	/Umamaheswari Ramachandran/	Date Considered	07/20/2010

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

I Applicant's unique citation designation number (costonal). 2 Applicant is to place a check mark here if English language Translation is statemed.

This solication of information is required by 37 CFR 138. The information is required to obtain or retain a benefit by the public which is to fee (and by the USPTO to process) an application. Confidentially is governed by 35 U.S.C. 122 and 37 CFR 1.14. This collection is estimated to take 2 hours to complete, including gathering, preprint, and submitting the completed application from to the USPTO. Time will very depending upon the inclination calculation and the completed application from the use USPTO. The will very depending upon the inclination calculation and the complete application from the use USPTO. The will very depending upon the inclination calculation and the complete application from the use USPTO. The will very depending upon the inclination calculation and the complete application from the use of the us